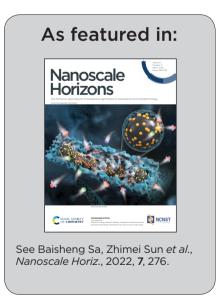


Showcasing research from Yinggan Zhang (Xiamen University), Baisheng Sa (Fuzhou University), Zhimei Sun (Beihang University) *et al.*

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Nanoscale Horizons



COMMUNICATION

View Article Online



Cite this: Nanoscale Horiz., 2022, 7.276

Received 24th November 2021, Accepted 14th January 2022

DOI: 10.1039/d1nh00621e

rsc.li/nanoscale-horizons

Computational design of double transition metal MXenes with intrinsic magnetic properties†

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Two-dimensional transition metal carbides (MXenes) have great potential to achieve intrinsic magnetism due to their available chemical and structural diversity. In this work, by spin-polarized density functional theory calculations, we designed and comprehensively investigated 50 double transition metal (DTM) MXenes MCr₂CT_x (T = H, O, F, OH, or bare) based on the chemical formula of M_2C (M = Sc, Y, Ti, Zr, Hf, V, Nb, Ta, Mo, W). We highlight that ferromagnetic half-metallicity, antiferromagnetic semiconduction, as well as antiferromagnetic half-metallicity have been achieved in the DTM MXenes. Herein, ferromagnetic half-metallic ScCr₂C₂, $ScCr_2C_2H_2$, $ScCr_2C_2F_2$, and $YCr_2C_2H_2$ are characterized with wide band gaps and high Curie temperatures. Very interestingly, the ScCr₂C₂-based magnetic tunnel junction presents a tunnel magnetoresistance ratio as high as 176 000%. In addition, the antiferromagnetic semiconducting TiCr₂C₂, ZrCr₂C₂, and ZrCr₂C₂(OH)₂, possessing moderate band gaps and high Néel temperatures, have been predicted. Especially, the Néel temperature of ZrCr₂C₂(OH)₂ can reach 425 K. Moreover, the Dirac cone-like band structure feature is highlighted in antiferromagnetic half-metallic ZrCr₂C₂H₂. Our study provides a new potential strategy for designing MXenes in spintronics.

1. Introduction

Conventional electronics only make use of the charge of electrons for device operation. Distinct from that, spintronics takes the advantage of both the charge and spin degrees of

New concepts

Recently achieved two-dimensional (2D) intrinsic materials open the door for spintronic applications at the nanoscale. However, most 2D materials lack intrinsic magnetism, which hampers their practical application as spintronic devices. In this work, we have designed 50 double transition metal MXenes with intrinsic magnetism. Among them, we screened four FM half-metals, ten AFM semiconductors, and one AFM half-metal that can be used for spintronic device applications. The four FM half-metals are characterized with wide band gaps and high Curie temperatures. Moreover, the ScCr2C2-based magnetic tunnel junction presents a tunnel magnetoresistance ratio as high as 176 000%. In addition, three AFM semiconductors exhibit moderate band gaps and high Néel temperatures. Especially, the Néel temperature of ZrCr2C2(OH)2 can reach 425 K, which is higher than room temperature. Notably, the AFM half-metal ZrCr2C2H2 is featured with a Dirac cone-like band structure. Our study provides a new strategy for developing MXenes as intrinsically magnetic materials and paves the way for application of the MXene family in the field of spintronics.

freedom in electrons for information processing. 1,2 Meanwhile, as switching a spin state requires much less energy than controlling a charge current, spintronic devices can operate information storage by low-energy consumption, with no heat created.³ Thus, spintronics offer great opportunities in future high-speed and energy-saving operations for next-generation information technology. On the other hand, since the successful fabrication of graphene, two-dimensional (2D) crystalline materials have garnered tremendous attention for their novel physical properties. However, pristine graphene is intrinsically nonmagnetic, as are many other 2D materials.6 In recent years, diverse advanced methods, such as doping, defects, functionalization, etc., have been utilized to induce magnetism for graphene-based 2D materials.7 However, the magnetism of these materials is not robust, which hampers their practical application as spintronic devices.8 Much effort has been made to investigate intrinsic magnetic properties in 2D materials. For example, ferromagnetic half-metals ScCl and MnX (X = P, As) monolayers, 9,10 ferromagnetic semiconductor single-layer CrOX (X = Cl, Br), 11 and Dirac half-metal YN2 monolayers 12

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[†] Electronic supplementary information (ESI) available. See DOI: 10.1039/d1nh00621e

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VIIIA H 16 VIA He 13 IIIA 14 IVA 15 VA M Early transition metals X C and/or N VIIA IIA Li Be C 0 F Ne A Group 13/14 T Surface terminations P \mathbf{S} Cl Na Mg 12 IIB Al Si Ar 5 VB 6 VIB 11 IB IVB VIIB IIIB VIII-Ni K Ti Mn Zn Br Ca Sc Fe Co Cu Ge Kr Se Rb Y Zr Nb Mo Sr Tc Ru Rh Pd Cd In Sn Sb Te Xe Cs Ba Ta Re Os Ir Pt Au Hg Bi Po At Rn 89~103 Fr Ra Rf Db Bh Hs Mt Ds Cn

Fig. 1 Periodic table showing compositions of MAX phases and MXenes.

have been theoretically predicted. Recently, ferromagnetic CrI_3 monolayers, 13 $Cr_2Ge_2Te_6$ bilayers, 14 and Fe_3GeTe_2 monolayers 15 have been successfully synthesized experimentally. However, seeking intrinsic 2D magnetic materials is still a great ongoing challenge.

Fortunately, MXenes, 16-20 a series of 2D transition metal carbides with a general formula of $M_{n+1}X_nT_x$, (as represented in Fig. 1), where M is an early transition metal (e.g. Sc, Ti, Zr, Hf, V, Cr), X is carbon and/or nitrogen, T represents functional groups (such as O, OH, F), and n = 1, 2, or 3, hold huge promise for 2D intrinsic magnetism due to their remarkably rich variety of chemical and structural diversity. Interestingly, MXenes are characterized by distinct magnetic properties, such as ferromagnetic orders with a range of transport behaviors, including metallicity, half-metallicity, and semi-metallicity. 6,21-25 For instance, Ti₂C and Zr₂C are predicted to be ferromagnetic with intrinsic magnetism.²⁶ It is worth noting that antiferromagnetism in MXenes has also been reported in recent years. 27-29 Our previous work has demonstrated that Cr₂C MXenes is a ferromagnetic half metal, whereas functionalized Cr2C is an antiferromagnetic semiconductor.²⁷ Besides that, there is another type of MXenes, known as double transition metal (DTM) MXenes.^{30,31} The general formula of DTM MXene is $M_n M'_2 X_{n+1} T_r$. There is no experimentally synthesized or theoretically predicted nitride DTM MXene to date; thus, X only represents carbon in the formula. On the other hand, in DTM MXenes, transition metals are separated in different atomic planes, where inner M layers are sandwiched by outer M' layers.³⁰ The choice of outer M' layers is crucial for the design.32 Recently, DTM MXenes VCr2C2(OH)2, VCr2C2F2, and VCr₂C₂O₂ have been proven to be ferromagnets, while TiCr₂C₂F₂ and TiCr₂C₂(OH)₂ are antiferromagnets.²⁸ It is interesting to note that V₂C MXene shows no magnetism, whereas DTM VCr₂C₂(OH)₂, VCr₂C₂F₂, and VCr₂C₂O₂ exhibit ferromagnetism. 26,28 Moreover, Ti₂C energetically favors ferromagnetic ground states, while the favorable magnetic order for DTM ${\rm TiCr_2C_2F_2}$ and ${\rm TiCr_2C_2(OH)_2}$ is antiferromagnetic. 26,28 Very recently, a magnetic glass transition in ${\rm TiCr_2C_2T_x}$ was achieved experimentally. 33 Therefore, Cr might play a key role in the intrinsic magnetism in DTM MXenes, which makes a prudent design of Cr-based DTM MXene of great interest and importance.

By considering the abovementioned theoretical predictions as well as the strongly spin-polarized Cr atoms, in this study, we selected Cr layers as the outer M' layers to design a family of Cr-based DTM MXenes in the chemical formula MCr_2CT_x , where M = Sc, Y, Ti, Zr, Hf, V, Nb, Ta, Mo, or W, and <math>T = H, O, F, OH, or bare. Comprehensive investigations were performed for these 50 DTM MXenes. Ultimately, we have screened four FM half-metals, ten AFM semiconductors, and one AFM half-metal, which possess moderate band gaps and high estimated Curie/Néel temperatures, implying their enormous potential as spin-tronic materials.

2. Computational details

We studied the DTM MXenes based on spin-polarized density functional theory (DFT) calculations, which were adopted using the ALKEMIE platform 34,35 together with the Vienna *ab initio* simulation package (VASP). The interaction between ions and electrons was described by the projector augmented-wave (PAW) method. The generalized gradient approximation (GGA) with Perdew–Burke–Ernzerhof (PBE) formalism was employed to describe the electron exchange–correlation functional. GGA+U method was adopted to describe the strong-correlation effects for Ti and Cr atoms. Since the U values (3 eV) for Ti and Cr are widely used in previous MXene-related theoretical studies, we adopted 3 eV for Ti and Cr in our calculations. The vacuum space and cutoff energy were chosen to be 20 Å and 550 eV. K-points of $11 \times 11 \times 1$ were automatically generated by Monkhorst–Pack with Γ symmetry

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for structural optimizations and static calculations. The convergence criteria of both electrons and ions were 1×10^{-6} eV. We introduced the Heyd-Scuseria-Ernzerhof (HSE06)⁴⁴ hybrid density functional to precisely calculate the band gaps of DTM MXenes.

To investigate the magnetic properties quantitatively, the classical Heisenberg model was adopted to describe magnetic exchange interactions between Cr atoms, which can be expressed by the following equation: 9,45

$$H_{\text{spin}} = -\sum_{ij} J_1 S_i \cdot S_j - \sum_{ik} J_2 S_i \cdot S_k - \sum_{il} J_3 S_i \cdot S_l - \sum_{i} A (S_i^z)^2$$

$$(1)$$

where J_1 is the intra-plane magnetic exchange coupling parameter between sites i and j, J_2/J_3 are the inter-plane magnetic exchange coupling parameters between i and k/l, S is the net magnetic moment of Cr atoms, and A is an anisotropy energy constant. Herein, by mapping the total energies of DTM MXenes for FM, AFM1, AFM2, and AFM3 states, the exchange coupling constants can be written as the following equations:³²

$$E_{\text{FM}} = E_0 - (6J_1 + 3J_2 + 3J_3)|S|^2 - A|S|^2 \tag{2}$$

$$E_{AFM1} = E_0 - (6J_1 - 3J_2 - 3J_3)|S|^2 - A|S|^2$$
 (3)

$$E_{AFM2} = E_0 - (-2J_1 + J_2 - 3J_3)|S|^2 - A|S|^2$$
 (4)

$$E_{AFM3} = E_0 - (-2J_1 - J_2 - 3J_3)|S|^2 + A|S|^2$$
 (5)

By solving the above equations, we can evaluate the magnetic exchange parameters J_1 , J_2 , and J_3 , and thus perform spin dynamics to estimate the Curie/Néel temperature $(T_{\rm C}/T_{\rm N})$ of the magnetic DTM MXene materials. A 30 \times 30 \times 1 supercell honeycomb lattice with periodic boundary conduction was applied to perform the Metropolis Monte Carlo (MC) simulations. For each studied temperature, the simulations for the DTM MXene last for 10⁵ MC steps to reach the thermal equilibrium. $T_{\rm C}/T_{\rm N}$ can be estimated by locating the temperature at the peak position of the magnetic susceptibility, and the position of mean magnetic moment drastically drops to nearly zero. To establish the reliability of the simulations, we have reproduced the monolayer CrI_3 with the experimental T_C value of 45 K.13 The mean magnetic moment and the magnetic susceptibility of CrI3 are plotted in Fig. S1 (ESI†) by our MC method. And the estimated $T_{\rm C}$ is 46 K, which is in excellent agreement with the experimental $T_{\rm C}$ value, ¹³ suggesting the validity of our simulation method.

The spin-dependent transport calculations are performed by density functional theory (DFT) with the nonequilibrium Green's function (NEGF),46 which is implemented in the QuantumWise Atomistix Toolkit (QuantumATK) Q-2021.06 package. 47 The exchange and correctional interactions of electrons were described by the GGA-PBE form functional, with a linear combination of atomic orbitals (LCAO) norm-conserving PseudoDojo pseudopotential. 48 The double-zeta basis set used to expand wave functions was performed for the calculations. The exchange-correlation potential was described based on the GGA+U approach, and the on-site effective interaction parameter U = 3.0 eV is used for

d-electrons of Cr atoms.^{6,40} DFT-D3 method was employed to deal with the interlayer van der Waals force. 49 The plane-wave cutoff is 105 hartree, and the average numerical tolerance was less than 10^{-6} eV for the self-consistent calculation. The Monkhorst k-point mesh for the self-consistent calculation is $10 \times 10 \times 100$. The left and right electrode temperatures are set to 300 K. To ensure the accuracy of the calculated results, a 151 × 151 Monkhorst-Pack grid is used for the spin-resolved transmission coefficient calculation.

Results and discussion

3.1. Structure and magnetism screening

MXenes are usually etched from their bulk MAX phase in hydrofluoric acid (HF) solution, where A represents group 13 and 14 elements from the periodic table (e.g. Si, Al, Ge or Sn). 16,50 Thus, the surface of MXenes is often terminated by O, F, and/or OH. 21,51 It has been recently reported that the bare MXenes (without surface termination) were fabricated successfully.52 To date, eleven M2C MXenes (Sc2C, Y2C, Ti2C, Zr₂C, Hf₂C, V₂C, Nb₂C, Ta₂C, Cr₂C, Mo₂C, W₂C) have been theoretically predicted or synthesized experimentally. 53-55 Therefore, we consider four functional groups (H, O, OH, F) and bare MXenes based on all these M2C MXenes to design Crbased DTM MXenes in the chemical formula of MCr₂CT_r (M = Sc, Y, Ti, Zr, Hf, V, Nb, Ta, Mo, W) in the present study (resulting in a total of 50 MXenes). There are three possible atomic configurations for the terminations on MXene, as depicted in Fig. 2: up and down terminations located toward the C atoms (marked as Model I); up and down terminations positioned above the middle M atoms (marked as Model II); and up terminations located above the C atoms and down terminations located on the middle M atoms (marked as Model III), i.e., a mixture of Model I and Model II. Since magnetic states may affect the stability of the structures, we considered these three DTM MCr₂CT_x models with nonmagnetic (NM), ferromagnetic (FM), and three antiferromagnetic (AFM) orders, as displayed in Fig. 3.

Full geometry optimizations were performed for DTM MCr₂CT_x with all the three termination configuration models and different magnetic orders to evaluate the energetically favorable atomic arrangements. The calculated energies for the most stable models and preferred magnetic orders of DTM $MCr_2C_2T_r$ are summed up in Tables S1-S10 (ESI†). The results show that the spin-unpolarized states present higher total energy than spin-polarized states for all the DTM MCr₂CT_x, and the energy difference between spin-unpolarized and spin-polarized states can reach as high as 2-3 eV per Cr atom. For the three termination configuration models, Model II is the energetically preferred atomic arrangement for a majority of the DTM MCr₂CT_x, regardless of NM, FM, or AFM states; only 22 MXenes in all the investigated 200 MXenes were the exception (highlighted with blue background in Tables S1-S10, ESI†). Moreover, FM or AFM1 arrangements are the energetically favorable configurations for all the explored DTM MXenes, except for ScCr₂C₂O₂ and YCr₂C₂O₂, which prefer the AFM3

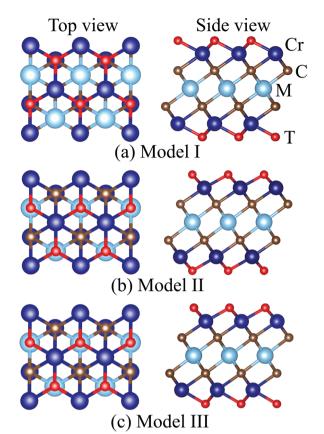


Fig. 2 Top and side views of different termination configuration models for DTM MCr₂CT_x.

magnetic arrangements. Such results agree well with previous MXene-related works. 21,28,56

To evaluate the stable magnetic orders, the ground state magnetic ordering for DTM MCr₂C₂T₂ is summarized in Fig. 4. As shown, all the H-terminated DTM MXenes have the same magnetic ground states as the corresponding bare MCr₂C₂

MXenes. For example, YCr₂C₂H₂ and YCr₂C₂ prefer the same FM states, while the other surface functional terminations (O, OH, F) do not present a clear pattern. Furthermore, Fig. 4 illustrates the transport behaviors for DTM MCr₂C₂T₂ as well. It can be concluded that the transport behavior of MCr₂C₂T₂ shows sensitive dependence on the center M layers. For example, all the VB and VIB DTM MXenes MCr_2CT_x (M = V, Nb, Ta, Mo, W) are metallic regardless of the surface terminations, among which 16 MXenes prefer FM state, with the other 9 MXenes taking AFM states as the stable magnetic orders. For a vivid view, Fig. S2–S6 (ESI†) plots the density of states (DOS) of these VB and VIB DTM MXenes. As is displayed, for the majority of the MXenes, the states at Fermi level are mainly occupied by d orbits from Cr and M atoms, while C-2p orbits and the orbits from functional groups make very little contribution. On the other hand, the IIIB and IVB DTM MXenes MCr_2CT_x (M = Sc, Y, Ti, Zr, Hf) exhibit diverse magnetic orders and transport behaviors, some of which are FM half-metallic, AFM semiconducting, and AFM half-metallic. Herein, the energy band diagrams of magnetic semiconductor and half metal are displayed in Fig. 5. The corresponding DOS of these IIIB and IVB DTM MXenes are presented in Fig. S7-S11 (ESI†), among which 9 MXenes are in FM ground state, while the other 16 MXenes are AFM ground states. The detailed analyses of the magnetic properties for these novel DTM MCr₂CT_x MXenes are presented in the following.

3.2. FM half-metallic properties

Half-metals were first reported by de Groot. They present a metallic DOS at the Fermi level in one spin direction and a finite band gap in another spin direction.⁵⁷ The remarkable feature of half-metallic materials is 100% spin polarization with high-efficiency spin injection, giving enormous potential for spintronic devices, such as electrode materials for magnetic tunneling junctions and spin field-effect transistors.^{58,59} Previous studies have demonstrated that the introduction of an

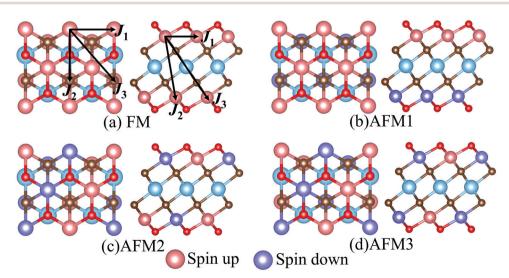


Fig. 3 Top and side views of possible magnetic order configurations for DTM MCr₂CT_x: (a) FM, (b) AFM1, (c) AFM2, (d) AFM3. The spin exchange paths are marked in (a).

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ZrCr₂C₂ HfCr₂C₂ WCr₂C₂ ScCr₂C₂ YCr₂C₂ TiCr₂C₂ VCr₂C₂ NbCr₂C₂ TaCr₂C₂ MoCr₂C₂ S S S H M M M M M Bare M H S S S M H Η M M Μ M 0 Μ M Μ M M M M Μ M Μ S S S M F H M M M M M S S OH Μ M M M M M M

FM order AFM order H: Half-Metallic M: Metallic S: Semiconducting

Fig. 4 Summary of ground state magnetic orderings and transport behaviors for $MCr_2C_2T_2$ (M = Sc, Y, Ti, Zr, Hf, V, Nb, Ta, Mo, W; T = H, O, F, OH, or bare). The orange and green background correspond to FM and AFM orders, respectively. The letters H, M, and S represent half-metallic, metallic, and semiconducting transport behavior, respectively.

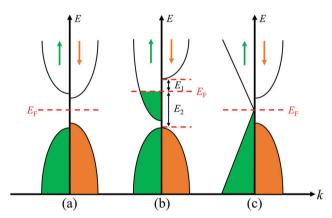


Fig. 5 Energy band diagrams for magnetic (a) semiconductor, (b) half metal, and (c) Dirac half metal.

electric field or edge modification to graphene can realize 100% spin polarization; however, these will add difficulty for application and fabrication in practice.^{60,61} Therefore, the search for intrinsically half-metallic 2D materials with high Curie temperature is highly desired.

Significantly, in the investigated DTM MCr_2CT_x MXenes, $ScCr_2C_2$, $ScCr_2C_2H_2$, $ScCr_2C_2F_2$, and $YCr_2C_2H_2$ exhibit FM half-metallic features. Their calculated minority-spin band gap and half-metallic band gap from the PBE+U and HSE06 method are summarized in Table 1. Herein, the half-metallic band gaps are evaluated by the energy difference between the Fermi level and the nearest minority-spin band around the Fermi level, 22 *i.e.*, the minimum of E_1 and E_2 in Fig. 5(b), which is crucial for preventing a magnetic spin flip transition. As displayed in Table 1, the HSE06 approach provides much higher minority-spin band gap than the PBE+U method, ranging from 1.15 eV to 2.38 eV. Moreover, the half-metallic band

Table 1 The calculated minority-spin band gaps (eV) and half-metallic band gaps (eV) of DTM MXenes $ScCr_2C_2$, $ScCr_2C_2H_2$, $ScCr_2C_2F_2$, and $YCr_2C_2H_2$ by PBE+U and HSE06 methods

	PBE + U		HSE06			
Structures	Minority-spin	Half-metallic	Minority-spin	Half-metallic		
ScCr ₂ C ₂	1.35	0.03	2.38	0.80		
$ScCr_2C_2H_2$	0.75	0.22	1.48	0.21		
$ScCr_2C_2F_2$	1.15	0.04	1.99	0.45		
$YCr_2C_2H_2$	0.34	0.03	1.15	0.15		

gaps of $ScCr_2C_2$ and $ScCr_2C_2F_2$ are 0.80 eV and 0.45 eV, respectively, from the HSE06 functional. Such values are comparable with those for double perovskites.⁵⁸ As discussed, these four DTM MXenes hold enormous promise as spintronic devices, especially $ScCr_2C_2$ and $ScCr_2C_2H_2$, which possess high half-metallic band gap and moderate minority-spin band gap.

The magnetic and electronic properties of these four DTM MXenes are further explored. Taking ScCr₂C₂F₂ as an example, the spin-dependent electronic band structure and spin-resolved density of states of ScCr₂C₂F₂ by HSE06 approach are illustrated in Fig. 6. As presented, the band structure exhibits metallic character as the bands slightly cross the Fermi level in one spin channel, while for the other channel, a wide indirect band up of 1.99 eV is observed with the conduction band minimum (CBM) and valence band maximum (VBM) located at the M and Γ points, respectively. The CBM is mainly donated by 3d orbits from Cr and Sc atoms, and the VBM is predominately contributed by 2p and 3d orbits from C atoms and Sc atoms, respectively. It is worth noting that in major-spin electrons, only one band slightly crosses the Fermi level, and the higher band holds a gap with respect to the crossing band; this may be modulated by doping or strain engineering to propose a FM semiconducting material.⁵⁶ The spin-dependent band structure

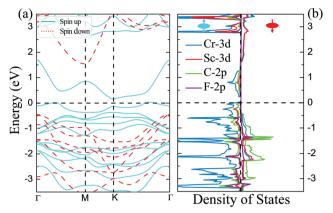


Fig. 6 (a) Spin-dependent electronic band structure and (b) spin-resolved density of states of ScCr₂C₂F₂ obtained by HSE06 approach.

and DOS of ScCr₂C₂, ScCr₂C₂H₂, and YCr₂C₂H₂ are plotted in Fig. S12-S14 (ESI†), respectively, which show very similar electronic and magnetic features to ScCr₂C₂F₂.

To give further insight into the intrinsic magnetic properties, Fig. 7 illustrates the band diagram model and spin density for ScCr₂C₂F₂. As is shown, one Cr atom donates one 4s electron and three 3d electrons, and the other Cr atom contributes one 4s electron and two 3d electrons to the surrounding C and F atoms, while the Sc atom supplies two 4s electrons and one 3d electron to C atoms, resulting in the nominal oxidation states (Cr⁴⁺, Cr³⁺, Sc³⁺) and reduction states (C4-, F1-). Hence, in the energy range from oxidation states to reduction states, the bonding σ orbits are fully occupied, with the anti-bonding σ^* orbits remaining empty.^{6,62} However, these orbits' influence on the magnetic behavior is very limited.⁴³ The energy states between the bonding and anti-bonding orbits are responsible for the electronic and magnetic properties,

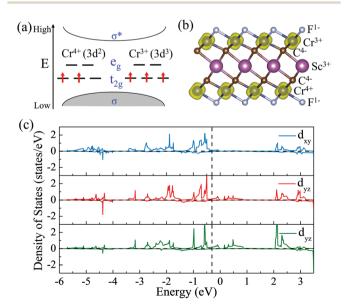


Fig. 7 (a) The band diagram model that predicts the magnetic properties of $ScCr_2C_2F_2$. (b) Side views of spin density for $ScCr_2C_2F_2$ MXenes. (c) Partial density of states (PDOS) of the Cr d_{xy} , d_{yz} , and d_{xz} orbitals in $ScCr_2C_2F_2$.

especially the partially filled Cr non-bonding 3d orbits. In this situation, the octahedral crystal field composed of Cr atoms under D_{3d} symmetry and the nearest surrounding C and F atoms break the non-bonding 3d orbits' degeneracy, splitting into two bands: the high energy states e_{g} ($d_{x^{2}-v^{2}}$ and $d_{z^{2}}$) and the lower band t_{2g} (d_{xv} , d_{vz} and d_{x2}). In the equilibrium ScCr₂C₂F₂ structure, transition metal Sc atoms have little effect on magnetic properties due to their electronic arrangements [Ar]3d⁰, leaving empty states of Sc d orbits, while the other transition metal Cr atoms play a vital role in the magnetic behaviors. The electronic arrangements of Cr atoms are [Ar]3d² and [Ar]3d³, leading to two and three electrons in the non-bonding states of Cr atoms, respectively. According to Hund's rule, electrons will primarily fill the lower energy states; thus, the remaining electrons will partially occupy the t2g bands, resulting in two electrons from one Cr atom filling two orbits of the t2g band, and the other Cr atom's three electrons half-occupy each t2g orbit. Taken together, a local spontaneous magnetic moment of $5\mu_{\rm B}$ for the two Cr atoms is induced. Evidently, the magnetic moment by our DFT calculation is $\sim 5\mu_{\rm B}$ (2.5 $\mu_{\rm B}$ per Cr atom), implying the validity of the above physical model depicted in Fig. 7. As the PDOS of Cr displays in Fig. 7(c), the d_{xy} , d_{yz} and d_{xz} orbitals show similar orbital split: the spin-up orbitals are occupied, while the spin-down orbitals are empty. These nearly half-occupied orbitals are consistent with our physical mode in Fig. 7(a). Furthermore, the stability of ScCr₂C₂F₂ has been assessed by ab initio molecular dynamics (AIMD) calculations. As the results present in Fig. S15 (ESI†), the atoms are well maintained around their equilibrium positions at 9 ps, and the total energy shows little variation in time from 0 to 9 ps at 300 K, indicating the stability of ScCr₂C₂F₂.

To guarantee stability during practical application as spintronic devices, we further extended the investigations of these four halfmetallic MXenes to the Curie temperature (T_C) by MC simulation. The total energy differences of various magnetic states and magnetic coupling parameters are listed in Table 2. The positive J_1 and J_2 values favor ferromagnetic alignment. The simulated magnetic moment and magnetic susceptibility as a function of temperature are displayed in Fig. 8. As presented in Table 2 and Fig. 8(b), the calculated T_C values for ScCr₂C₂, ScCr₂C₂H₂, ScCr₂C₂F₂, and YCr₂C₂H₂ are 187 K, 135 K, 230 K, and 109 K, respectively. Note that the calculated $T_{\rm C}$ values for the four half-metallic MXenes are significantly higher than those ever reported, e.g., 45 K for CrI₃ monolayers and 30 K for Cr₂Ge₂Te₆ bilayers. 13,14

Current-perpendicular-to-plane magnetic tunnel junction (CPP-MTJ) is regarded as one of the most significant spintronics devices, attracting global attention from both the

Table 2 The total energy differences of FM with different AFM states ($E_{\text{FM-AFM}}$, meV) for DTM half-metallic MXenes in a 2 \times 1 \times 1 supercell, the magnetic coupling parameters (J₁, J₂, J₃, meV) according to the Heisenberg model, and the calculated $T_{\rm C}$ (K) by MC method

Materials	$E_{\rm FM-AFM1}$	$E_{\rm FM-AFM2}$	$E_{\rm FM-AFM3}$	J_1	J_2	J_3	T_{C}
ScCr ₂ C ₂	-306	-679	-837	4.833	1.958	0.875	187
$ScCr_2C_2H_2$	-111	-563	-650	3.826	1.375	-0.347	135
$ScCr_2C_2F_2$	-438	-371	-556	1.698	4.327	-0.271	230
$YCr_{2}C_{2}H_{2} \\$	-132	-567	-572	3.492	0.953	0.272	109

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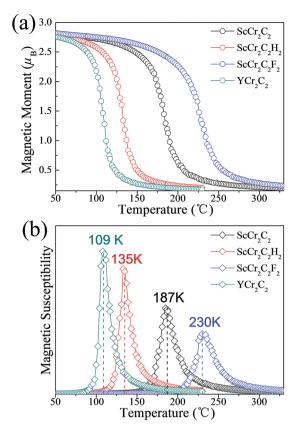


Fig. 8 (a) Magnetic moment of Cr atoms and (b) magnetic susceptibility as a function of temperature for $ScCr_2C_2$, $ScCr_2C_2H_2$, $ScCr_2C_2F_2$, and $YCr_2C_2H_2$.

theoretical and experimental points of view. 63-65 Due to the weak vdW interaction between the 2D materials in CPP-MTJs, the influence of the electronic structure of half-metallic monolayer is limited, which leads to the significant tunnel magnetoresistance properties. By taking ScCr₂C₂ as an example, we designed a vdW CPP-MTJ based on ferromagnetic half-metals to estimate the spintronic applications of these DTM MXenes. Fig. 9(a) illustrates the atomic structure of the ScCr₂C₂-based vdW CPP-MTJ, which is constructed by two electrode layers of 1T-MoS₂, a ferromagnetic layer of ScCr₂C₂, and a tunnel barrier layer of 2H-MoS₂. Herein, the optimized lattice constants are 3.191 Å for both 2H-MoS2 and 1T-MoS2, which possess only 1.63% mismatch to monolayer ScCr₂C₂ (3.244 Å). The metallic and semiconductor properties of 1T-MoS2 and 2H-MoS2 are suitable for functioning as the electrode and tunnel barrier. By applying external magnetic fields, the magnetic configurations for two ScCr₂C₂ ferromagnetic layers can be implemented: the parallel configuration (PC) and antiparallel configuration (APC). We therefore considered the zero-bias transmission coefficient curves from -1 eV to 1 eV of the $ScCr_2C_2$ -based vdW MTJ, as plotted in Fig. 9(b) and (c). For the PC state, it can be observed from Fig. 9(b) that there are three significant peak values located at -0.7 eV, 0.3 eV and 0.6 eV in the spin-up channel, and the transmission coefficient at the Fermi level (0 eV) for the spin-up channel (G_{PC}^{\uparrow}) is 0.032. On the other

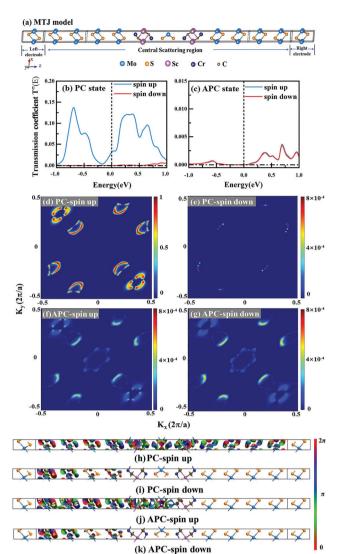


Fig. 9 (a) Schematic diagram of 1T-MoS₂/ScCr₂C₂/2H-MoS₂/ScCr₂C₂/1T-MoS₂ vdW CPP-MTJ. The zero-bias transmission coefficient curves for MTJ in (b) PC and (c) APC. Spin-dependent transmission spectra for (d) spin-up and (e) spin-down channels of PC, and for (f) spin-up and (g) spin-down channels of APC at zero bias voltage and E=0 eV. The contour plot of the transmission eigenstates for (h) spin-up and (i) spin-down channels of PC, and for (j) spin-up and (k) spin-down channels of APC at E=0 eV and E=00 eV and E=01 eV.

hand, the transmission coefficient curves near the Fermi level are always negligible in the spin-down channel, and the transmission coefficient at the Fermi level for spin-down channel $\left(G_{\rm PC}^{\downarrow}\right)$ is only 5.31×10^{-7} . When the MTJ is in PC state, the transmission coefficients can hardly be detected near the Fermi level for both channels, as is shown in Fig. 9(c). The transmission coefficient at the Fermi level for spin-up channel $\left(G_{\rm APC}^{\uparrow}\right)$ is 8.71×10^{-6} , and that of spin-down channel $\left(G_{\rm APC}^{\downarrow}\right)$ is 9.44×10^{-6} . The tunnel magnetoresistance (TMR) ratio is a very important performance index of MTJ, 66,67 which is defined by:

TMR =
$$[(G_{PC} - G_{APC})/G_{APC}] \times 100\%$$
 (6)

where G_{PC} and G_{APC} represent total transmission coefficients at the Fermi level of PC and APC states; thus, $G_{PC} = G_{PC}^{\uparrow} + G_{PC}^{\downarrow}$, $G_{\rm APC} = G_{\rm APC}^{\uparrow} + G_{\rm APC}^{\downarrow}$. Herein, the calculated TMR ratio for the ScCr₂C₂-based vdW MTJ reaches up to 176 000% at zero bias, indicating the promising application of the 1T-MoS₂/ScCr₂C₂/ 2H-MoS₂/ScCr₂C₂/1T-MoS₂ vdW CPP-MTJ in spintronic devices.

To understand more details about the transmission behavior of the ScCr₂C₂-based vdW CPP-MTJ, the spin-dependent transmission spectra and transmission eigenfunctions were calculated. Fig. 9(d)–(g) represent the spin-dependent transmission spectra at the Fermi level for different magnetic configurations as a function of the k-vector in the 2D Brillouin zone perpendicular to the transport direction. The results present that the transmission coefficients are localized on six symmetrical regions along the diagonals in the whole wave vector space for all cases. Interestingly, in PC state, the transmission coefficients of the spin-up channel at these regions are several orders of magnitude larger than those of the spin-down channel. Hence, the spin-polarized electrons of the left electrode are mainly contributed by the spin-up electrons, which could pass through the barrier layer to the right electrode, corresponding to the ON state of the device. Whereas for APC state, the transmission coefficients of both the spin-up and spin-down channels at these regions are negligible, which result in an extreme suppression of the transmission current, corresponding to the OFF state of the device. Fig. 9(h)-(k) illustrate transmission eigenfunctions for E = 0 eV and $(k_x, k_y) = (0.34,$ 0.18). As shown in Fig. 9(h) and (j), for both PC and APC states, all the spin-up electrons can pass through the left ScCr₂C₂ layer and middle 2H-MoS2 barrier layer. The spin-up electrons can only go through the right ScCr₂C₂ layer for PC state, whereas they are reflected by the right ScCr₂C₂ layer for APC state. As a result, the transmission eigenstates of the spin-up channel show high value in the whole central region, while those of the spin-down channel are terminated at the right ScCr2C2 layer. On the other hand, as shown in Fig. 9(i) and (k), the transmission eigenstates of spin-down channels are terminated at the left ScCr₂C₂ layer for both PC and APC states due to the half-metallicity of the ScCr₂C₂ monolayer. In addition to the transmission eigenstates, the spin-resolved projected local density of states (PLDOS) of the ScCr₂C₂-based vdW CPP-MTJ in Fig. S16 (ESI†) can also get similar results. As a result, the spin-up electrons in PC state play a decisive role in the spin transport behavior of the ScCr₂C₂-based vdW CPP-MTJ.

3.3. AFM semiconducting and half-metallic properties

Aside from 2D FM materials, 2D AFM materials are another promising candidate for the next-generation spintronic applications. 42 AFM materials exhibit zero magnetic moment due to their ordered magnetic moments taking opposite directions between individual atomic sites. As a consequence, the atoms in AFM materials will not affect each other magnetically; hence, extremely dense elements can be integrated in AFM spintronic devices. Moreover, AFM materials are insensitive to external magnetic fields, hold a fast switching between

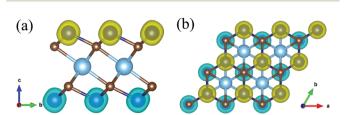
Table 3 The calculated band gaps (eV) for DTM MXene AFM semiconductors by PBE+U and HSE06 approach

	$\mathrm{PBE} + U$		HSE06		
Structure	Spin up	Spin down	Spin up	Spin down	
TiCr ₂ C ₂	0.32	0.32	0.56	0.56	
TiCr ₂ C ₂ H ₂	0.51	0.53	0.99	1.00	
TiCr ₂ C ₂ F ₂	0.81	0.77	1.47	1.41	
$ZrCr_2C_2$	0.31	0.37	0.56	0.64	
ZrCr ₂ C ₂ F ₂	0.72	0.87	1.33	1.52	
$ZrCr_2C_2(OH)_2$	0.31	0.31	0.64	0.64	
HfCr ₂ C ₂	0.28	0.24	0.53	0.51	
HfCr ₂ C ₂ H ₂	0.61	0.61	1.02	1.02	
HfCr ₂ C2F ₂	0.94	0.92	1.63	1.62	
$HfCr_2C_2(OH)_2$	0.32	0.32	0.61	0.61	

different magnetic states, and possess intrinsic high frequencies of AFM dynamics.⁶⁸ Besides the above merits, AFM semiconductors have great potential for nanoscale electronic devices because of the existence of intrinsic band gaps. 69

Very attractively, in this work, we found ten AFM semiconductors from the explored DTM MXenes. The M elements of these MCr₂C₂T₂ MXenes are situated at group IVB (M = Ti, Zr and Hf) of the periodic table. We then calculated the band gaps for the ten DTM MXenes, and the results are summed up in Table 3. We can see that HSE06 provides higher band gaps than PBE+U, with the band gaps ranging from 0.56 eV to 1.63 eV. Notably, the band gaps for the spin-up and spin-down channels are not equal in some MXenes; this can be explained by the DOS being asymmetrical in different channels, but the systems exhibit no net magnetization. Deep understanding of the electronic properties has been explored by the spin-dependent band structures and spin-resolved DOSs, as displayed in Fig. S17-S26 (ESI†). All the AFM semiconductors are characterized by indirect band gaps, with most of the VBM located at Γ points, and most of the CBM positioned at M points. In detail, their VBM are mainly occupied by 3d orbits of Cr atoms, while the CBM are contributed by d orbits from Cr and middle transition atoms. Note that all the AFM semiconductors prefer AFM1 arrangement as the ground state. Fig. 10 shows the spin density of TiCr₂C₂ at the AFM magnetic configurations as an example. Obviously, the Cr atoms completely donated the magnetic moments, and the nearest interlayer Cr atoms are antiferromagnetically coupled with each other, resulting in the zero magnetic moment in TiCr₂C₂ MXene.

We have further calculated the Néel temperature of the AFM DTM MXenes by MC simulations. The magnetic exchange



(a) Side view and (b) top view of the spin density of TiCr₂C₂ MXene. The yellow and cyan colors represent spin-up and spin-down orientations, respectively.

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Table 4 The total energy differences of AFM1 with FM ($E_{AFM1-FM}$, meV), AFM2 ($E_{AFM1-AFM2}$, meV), and AFM3 ($E_{AFM1-AFM3}$, meV) states for ten AFM semiconducting MXenes and half-metal $ZrCr_2C_2H_2$ in a 2 \times 1 \times 1 supercell, the magnetic coupling parameters $(J_1, J_2, J_3, \text{ meV})$ according to the Heisenberg model, and the calculated $T_{\rm N}$ (K) by MC method

Materials	$E_{\rm AFM1-} \\ {\rm FM}$	$E_{ m AFM1-}$	$E_{ m AFM1-}$	J_1	J_2	J_3	$T_{ m N}$
TiCr ₂ C ₂	-535	-426	-215	6.27	1 -3.6	39 -0.20	04 304
$TiCr_2C_2H_2$	-578	-621	-280	3.19	0 - 1.6	644 - 0.94	19 141
$TiCr_2C_2F_2$	-487	-779	-224	3.61	7 0.4	75 - 2.54	19 90
$ZrCr_2C_2$	-548	-1552	-316	6.19	4 4.7	78 -7.70	04 342
$ZrCr_2C_2F_2$	-919	-935	-484	4.75	8 - 3.2	253 - 1.22	27 245
$ZrCr_2C_2(OH)_2$	-1211	-391	-535	4.74	6 - 7.3	26 2.37	73 425
$HfCr_2C_2$	-596	-245	-343	3.26	0 - 1.7	757 - 2.85	54 150
$HfCr_2C_2H_2$	-892	-671	-342	4.23	8 - 3.9	06 0.73	35 270
$HfCr_2C2F_2$	-956	-905	-510	4.68	8 - 3.8	395 - 0.82	27 282
$HfCr_2C_2(OH)_2$	-829	-658	-491	3.45	8 - 4.5	98 0.05	1 278
ZrCr ₂ C ₂ H ₂	-741	-876	-342	4.35	7 - 1.5	571 –1. 77	6 165

parameters J_1 , J_2 , and J_3 have been firstly evaluated in Table 4; thus, by performed spin dynamics, the estimate Néel temperature can be estimated. The magnetic moment of Cr atoms and their magnetic susceptibility as a function of temperature are presented in Fig. 11. The corresponding T_N values range from 90 K to 425 K, as summed up in Table 4 and Fig. 11. Generally, the three ZrCr2C2Tx MXenes have a relatively higher Néel temperature than the three $TiCr_2C_2T_x$ and the four $HfCr_2C_2T_x$ MXenes. Significantly, the ZrCr₂C₂(OH)₂ MXene holds the highest T_N above room temperature due to its large energy difference between AFM1 and FM magnetic orders.

Besides the AFM semiconductors mentioned, there exists another novel magnetic property with AFM arrangement, namely, the AFM half-metal, which was first proposed by van Leuken and de Groot.⁷⁰ An AFM half-metal not only can

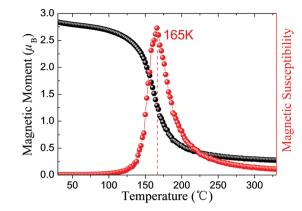


Fig. 12 Magnetic moment of Cr atoms and magnetic susceptibility as a function of temperature for ZrCr₂C₂H₂ AFM half-metal.

transport a 100% spin-polarized charge with zero net magnetization, but also has the feature of generating no macroscopic magnetic field. Hence, AFM half-metals are expected to be an important species of spintronic material with distinct applications, such as probes in spin-polarized scanning tunneling microscopes.⁷¹ Conventionally, the electronic structures of AFM materials in spin-up channel and spin-down channel are usually identical with a symmetry relation, which leads to the vanishing of the net magnetic moment. Thus, the conduction electrons are unspin-polarized. By careful selection, one can discover an AFM material with half-metallic feature. In this case, the polarization of the conduction electrons is not in contradiction with the existence of AFM. This class of materials is called half-metallic antiferromagnet. Coincidentally, the sites of opposite spin of some investigated DTM MXenes are not symmetric, as mentioned before. Therefore, a blueprint came

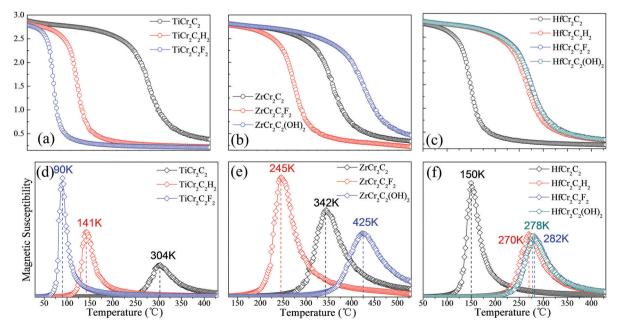
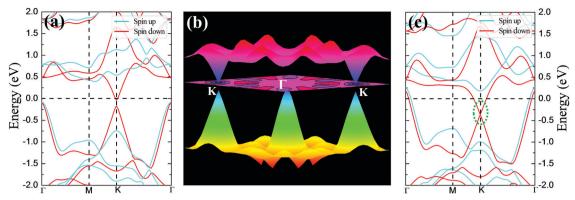


Fig. 11 Magnetic moment of Cr atoms and magnetic susceptibility as a function of temperature for (a and d) $TiCr_2C_2T_x$, (b and e) $TiCr_2C_2T_x$, and (c and f) HfCr₂C₂T_x AFM semiconductors, respectively.



 $\textbf{Fig. 13} \quad \text{Spin-dependent band structure of } ZrCr_2C_2H_2 \text{ under (a) strain-free condition and (c) 5\% tensile strain; (b) 3D band profile around the Fermi level tensile strain; (b) 3D band profile around the Fermi level tensile strain; (c) 3D band profile around the Fermi level tensile strain; (d) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain; (e) 3D band profile around the Fermi level tensile strain te$ corresponding to (a).

to our mind: AFM DTM MXenes in our study may be endowed with this novel property.

Excitingly, intrinsic AFM half-metallic property was characterized in DTM ZrCr₂C₂H₂ from our screening. The energy differences between different states are listed in Table 4, and the AFM1 magnetic arrangements are the preferred configurations for ZrCr₂C₂H₂. Fig. 12 presents the magnetic moment of Cr atoms and magnetic susceptibility as a function of temperature for ZrCr₂C₂H₂ based on the exchange constants from Table 4, from which one can see that the estimated T_N value can reach as high as 165 K. Moreover, as the spin-dependent band structure displays in Fig. 13(a), ZrCr₂C₂H₂ shows metallic conduction feature for the spin-down direction, and a finite band gap in the spin-up direction. Hence, we proposed that DTM ZrCr₂C₂H₂ is an AFM half-metal with high Néel temperature.

From Fig. 13(a), another distinct feature of the spin-dependent band structure of ZrCr₂C₂H₂ is a Dirac cone-like structure at the K point, which is reminiscent of the anomalous electronic states observed in graphene and topological insulators. 72,73 Around the Dirac cone, the conduction and valence bands touch with linear dispersions on the Fermi level, inducing the so-called Dirac point. The Dirac point is responsible for many peculiar properties, such as high carrier mobility, which is beneficial for the design of highspeed electronic devices. 12,72,73 Based on this, a Dirac half-metal has emerged, characterized by conductivity in one spin direction with a Dirac cone in the other direction; the energy band diagrams for Dirac half metal are illustrated in Fig. 5(c). For DTM ZrCr₂C₂H₂, in spin-up channel, a band gap of 0.5 eV is clearly observed, while an opened Dirac cone positions at the K point of the first Brillouin zone. Fig. 13(b) further illustrates the 3D band profile around the Fermi level. Inspired by the fact that strain engineering is often adopted to manipulate the electronic structure of 2D materials, diverse tensile strains were applied on the DTM ZrCr2C2H2 to explore the variation of the Dirac cone-like feature. Interestingly, only a 5% tensile strain can close the gap of the cone at the K point. As displayed in Fig. 13(c), the Dirac point is located ~ 0.4 eV below the Fermi level, which indicates that the DTM ZrCr₂C₂H₂ is not a perfect Dirac half-metal. However, with the growing number of MXene family, more Dirac half-metals are expected to be found in other MXenes.74

4. Conclusions

In summary, we have designed and comprehensively studied 50 DTM MXenes MCr_2CT_x (T = H, O, F, OH, or bare) on the chemical formula of M₂C (M = Sc, Y, Ti, Zr, Hf, V, Nb, Ta, Mo, W) by first-principles calculations. Interestingly, the VB and VIB DTM MXenes MCr₂CT_x show metallic conductivity with AFM or FM magnetic orders. Moreover, various novel magnetic properties have been presented for IIIB and IVB DTM MCr₂CT_x MXenes. Notably, ScCr₂C₂, ScCr₂C₂H₂, ScCr₂C₂F₂, and YCr₂C₂H₂ exhibit FM halfmetallicity with wide band gaps and high Curie temperatures. The TMR ratio of the proposed 1T-MoS₂/ScCr₂C₂/2H-MoS₂/ScCr₂C₂/ 1T-MoS₂ vdW MTJ can reach up to 176 000% at zero bias. Another ten AFM semiconductors with band gaps ranging from 0.56 eV to 1.63 eV and Néel temperatures from 90 K to 425 K have been predicted. In addition, DTM ZrCr₂C₂H₂ is expected to be a halfmetallic antiferromagnet, the Néel temperature of which can reach 165 K. Very interestingly, there exists a Dirac-like cone at K points in the ZrCr2C2H2 band structure. Our study has provided a new strategy for developing MXenes as intrinsically magnetic materials and paves the way for application of the MXene family in the field of spintronics.

Conflicts of interest

The authors declare no competing financial interest.

Acknowledgements

This work was supported by the National Natural Science Foundation of China (No. 21973012, 51872017 and 51871009), the Natural Science Foundation of Fujian Province (Grant No. 2021J06011 and 2020J01351), the National Key Research and Development Program of China (No. 2017YFB0701701), and the "Qishan Scholar" Scientific Research Project of Fuzhou University.

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